

FORM PTO-1449				Atty. Docket No. XA-7431L		Appln. No. 10/759,603	
LIST OF DOCUMENTS CITED BY APPLICANT				Applicant Naomasa Shiraishi et al.			
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U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Sub-class	Filing Date
AM	AA	3,492,635	1/27/70	Farr	340	15.5	
AM	AB	3,630,598	12/28/71	Little, Jr.	350	157	
AM	AC	3,639,039	2/1/72	Rhodes, Jr.	350	162	
AM	AD	3,658,420	4/25/72	Axelrod	356	71	
AM	AE	3,729,252	4/24/73	Nelson	350	162	
AM	AF	3,770,340	11/6/73	Cronin et al.	350	162	
AM	AG	3,776,633	12/4/73	Frosch et al.	355	132	
AM	AH	4,132,479	1/2/79	Dubroecq et al.	355	71	
AM	AI	4,207,370	6/10/80	Liu	428	204	
AM	AJ	4,291,938	9/29/81	Wagner	350	91	
AM	AK	4,472,023	9/18/84	Yamamoto	350	162.11	
AM	AL	4,739,373	4/19/88	Nishi et al.	355	53	
AM	AM	4,749,278	6/7/88	van der Werf	356	401	
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AM	AN	0 346 844	12/20/89	EPO			
AM	AO	0 352 975	1/31/90	EPO			
AM	AP	59-83165	5/14/84	JAPAN			abstract
AM	AQ	61-41150	2/27/86	JAPAN			abstract
AM	AR	2-50417	2/20/90	JAPAN			abstract
AM	AS	2-48090	10/24/90	JAPAN			abstract
OTHER (including author, title, date, pertinent pages, etc.)							
AM	AT	"Extended Focal Depth Optical Microlithography", IBM Technical Disclosure Bulletin, Vol. 32, June 1989, pp 125-127.					
AM	AU	Delmer L. Fehrs et al., "Illuminator Modification of an Optical Aligner", KTI Microelectronics Seminar, Nov. 6-7, 1989, pp. 217-230.					
AM	AV	David J. Cronin et al., "Dynamic Coherent Optical System", Optical Engineering, March/April 1973, Vol. 12, pp. 50-55.					
Examiner Alan Mathews				Date Considered 11-23-2004			
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AM	AA*	4,778,275	10/18/88	van den Brink et al.	356	401	
AM	AB*	4,780,749	10/25/88	Schulman	357	12	
AM	AC*	4,789,222	12/6/88	Ota et al.	350	167	
AM	AD*	4,814,829	3/21/89	Kosugi et al.	355	43	
AM	AE*	4,828,392	5/9/89	Nomura et al.	356	401	
AM	AF*	4,841,341	6/20/89	Ogawa et al.	355	43	
AM	AG*	4,851,882	7/25/89	Takahashi et al.	355	46	
AM	AH*	4,853,756	8/1/89	Matsuki	355	71	
AM	AI*	4,854,669	8/8/89	Birnbach et al.	350	162.12	
AM	AJ*	4,931,830	6/5/90	Suwa et al.	355	71	
AM	AK*	4,947,413	8/7/90	Jewell et al.	378	34	
AM	AL*	4,970,546	11/13/90	Suzuki et al.	355	53	
AM	AM*	4,988,188	1/29/91	Ohta	353	122	
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AM	AT*	Victor Pol et al., "Excimer laser based lithography: a deep-ultraviolet wafer stepper for VLSI processing", <u>Optical Engineering</u> , Vol. 26, April 1987, pp. 311-318.					
AM	AU*	D. H. Barry, "Pattern recognition automatic fine alignment", <u>SPIE</u> , Vol. 334, 1982, pp. 10-16.					
AM	AV*	S. T. Yang et al., "Effect of central obscuration on image formation in projection lithography", <u>SPIE</u> , Vol. 1264, 1990, pp. 477-485.					
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AM	AA^	4,992,825	2/12/91	Fukuda et al.	355	53	
AM	AB^	5,004,348	4/2/91	Magome	356	401	
AM	AC^	5,091,744	2/25/92	Omata	355	53	
AM	AD^	5,121,160	6/9/92	Sano et al.	355	53	
AM	AE^	5,153,419	10/6/92	Takahashi	250	201.1	
AM	AF^	5,191,374	3/2/93	Hazama et al.	355	43	
AM	AG^	5,208,629	5/4/93	Matsuo et al.	355	53	
AM	AH^	5,237,367	8/17/93	Kudo	355	67	
AM	AI^	5,245,384	9/14/93	Mori	355	67	
AM	AJ^	5,264,898	11/23/93	Kamon et al.	355	67	
AM	AK^	5,286,963	2/15/94	Torigoe	250	201.2	
AM	AL^	5,309,198	5/3/94	Nakagawa	355	67	
AM	AM^	5,329,336	7/12/94	Hirano et al.	355	53	

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AM	AS^	Naomasa Shiraishi et al., "Optical/Laser Microlithography V", SPIE- The International Society for Optical Engineering, Vol. 1674, March 11-13 1992, pp. 741-752.
AM	AT^	George O. Reynolds, "A Concept for a High Resolution Optical Lithographic System for Producing One-Half Micron Linewidths", SPIE, Vol. 633, 1986, pp. 228-238.
AM	AU^	A. Szegvári, "On the use of an Illumination azimuth diaphragm during coaxial dark field illumination", January 28, 1923, pp. 1-11.

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<b>AM</b>	AA#	5,337,097	8/9/94	Suzuki et al.	353	101	
<b>AM</b>	AB#	5,392,094	2/21/95	Kudo	355	67	
<b>AM</b>	AC#	5,440,426	8/8/95	Sandstrom	359	559	
<b>AM</b>	AD#	5,446,587	8/29/95	Kang et al.	359	562	
<b>AM</b>	AE#	5,673,102	9/30/97	Suzuki et al.	355	53	
<b>AM</b>	AF#	Re 34,634	6/7/94	Konno et al.	362	268	
<b>AM</b>	AG#	5,586,170	11/94	Muraki	355	67	
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<b>AM</b>	AT#	George Needham, "The Practical Use of The Microscope Including Photomicrography", 1958, pp. 315-327 and 97					
<b>AM</b>	AU#	John Strong, "Concepts of Classical Optics", 1958, pp. 525-536.					
<b>AM</b>	AV#	Akira Imai et al., "Lens aberration measurement technique using attenuated phase-shifting mask", Device Development Center, Hitachi Ltd.					
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<b>AM</b>	AT+	Miyoko Noguchi et al., "Subhalf Micron Lithography System with Phase-Shifting Effect", <u>SPIE</u> , Vol. 1674, 1992, pp. 92-104.					
<b>AM</b>	AU+	N. Nomura et al., "Heterodyne Holographic Nanometer Alignment for a Wafer Stepper", <u>Microelectronic Engineering</u> 11, 1990, pp. 133-136.					
<b>AM</b>	AV+	Emi Tamechika et al., "Investigation of single sideband optical lithography using oblique incidence illumination", J. Vac. Sci. Technol. B, Nov/Dec 1992, pp. 3027-3031.					
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AM	AT	Keiichiro Tounai et al., "Resolution improvement with annular illumination", VLSI Development Division, NEC Corporation, 1992.					
AM	AU	H. Fukuda et al., "Characterization of Super-Resolution Photolithography", <u>IEEE</u> , 1992, pp. 3.2.1 - 3.2.4.					
AM	AV	Hiroshi Fukuda et al., "A New Pupil Filter for Annular Illumination in Optical Lithography", <u>Jpn. J. Appl. Phys.</u> , Vol. 31, 1992, pp 4126-4130.					
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<b>AM</b>	AT♦	Maksymilian Pluta, "Principles and Basic Properties" <u>Advanced Light Microscopy</u> , Vol. 1, 1988, pp. 460-463.					
<b>AM</b>	AU♦	H. Wolfgang Zieler, "Physical Optical Aspects of Image Formation", <u>The Optical Performance of the Light Microscope</u> , 1974, pp. 32-55.					
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AM	AR*	James R. Sheats et al., "Optical Lithography Modeling", <u>Microlithography Science and Technology</u> , Chapters 2-4, 1998, pp. 109-271.					
AM	AS*	Joseph W. Goodman, "Frequency Analysis of Optical Imaging Systems", <u>Introduction to Fourier Optics</u> , Chapter 6, 1968, pp. 101-197.					
AM	AT*	Maksymilian Pluta, "Specialized Methods", <u>Advanced Light Microscopy</u> , Vol. 2, 1989, pp. 100-113.					
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<b>AM</b>	AT◇	Satoru Asai, et al., "Improving projection lithography image illumination by using sources far from the optical axis", <u>J. Vac. Sci. Technol.</u> , Vol. 9, Nov/Dec 1991, pp. 2788-2791.					
<b>AM</b>	AU◇	B. J. Lin, "Optical Methods for Fine Line Lithography", <u>Fine Line Lithography</u> , Chapter 2, 1980, pp. 107-232.					
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AM	AA	4,497,015	1/85	Konno et al.	362	268	
AM	AB	4,952,815	8/90	Nishi	250	548	
AM	AC	5,307,207	4/94	Ichihara	367	259	
AM	AD	5,098,184	3/92	vanden Brandt et al.	353	38	
AM	AE	4,851,978	7/89	Ichihara	355	67	
AM	AF	5,153,773	10/92	Muraki et al.	362	268	
AM	AG	4,497,013	1/85	Ohta	362	268	
AM	AH	4,939,630	7/90	Kikuchi et al.	362	268	
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AM	AL	62-50811	10/87	JAPAN			partial
AM	AM	WO 92/03842	3/92	WIPO (abstract)			
AM	AN	61-91662	5/9/86	Japan			yes
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AM	AB	5,300,971	4/5/94	Kudo	355	67	
AM	AC	6,252,647	6/26/01	Shiraishi	355	53	
AM	AD	6,211,944	4/3/01	Shiraishi	355	53	
AM	AE	4,619,508	10/28/86	Shibuya et al.	355	67	
AM	AF	4,769,750	9/6/88	Matsumoto et al.	362	268	
AM	AG	4,974,919	12/4/90	Muraki et al.	362	268	
AM	AH	5,016,149	5/14/91	Tanaka	362	268	
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AM	AM	1,137,243	12/18/68	United Kingdom			
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<b>AM</b>	AB	4,637,691	1/87	Uehara et al.	359	727	
<b>AM</b>	AC	4,498,742	2/85	Uehara	359	727	
<b>AM</b>	AD	4,370,026	1/83	Dubroeucq et al.	355	71	
<b>AM</b>	AE	4,249,793	2/81	Uehara	359	727	
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AM	AC	4,275,288	06/23/81	Makosch et al.	219	121	
AM	AD	5,463,497	10/31/95	Muraki et al.	359	618	
AM	AE	4,241,389	12/23/80	Heimer	362	297	
AM	AF	4,547,037	10/15/85	Case	350	3.75	
AM	AG	4,389,701	01/21/83	Phillips	362	308	
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AM	AN	58-16214	01/29/83	Japan			Abstract
AM	AO	59-49514	03/22/84	Japan			Abstract
AM	AP	0 282 593	09/21/88	Europe			
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AM	AA	4,179,708	12/18/79	Sheng et al.	358	128	
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Examiner Initial		Document Number	Date	Country	Class	Sub-class	Translation
	AL						
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	AN						
	AO						
	AP						
	AQ						

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Examiner

Alan Mathew,

Date Considered

11-23-2004

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FORM PTO-1449

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XA-7431L

10/759,603



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Naomasa Shiraishi

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January 20, 2004

2851

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AM	AA	4,936,665	6/26/90	Whitney	350	451	
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